L Number	Hits	Search Text	DB	Time stamp
158	1	@ad<=20010111 and 'silicide' same 'natural oxide' same 'NH.sub.3' with 'plasma'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 14:02
159	3	@ad<=20010111 and 'titanium nitride' same 'natural oxide' same 'plasma'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 14:01
160	15	@ad<=20010111 and 'silicide' same 'natural oxide' same 'plasma'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 14:02
-	16	@ad<=20010111 and 'dielectric' with 'titanium' and 'conductive barrier' and 'conductive plug'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 07:26
-	173	@ad<=20010111 and (438/600).ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/06/11 11:43
-	49	@ad<=20010111 and (438/600).ccls. and 'titanium' and 'titanium nitride'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/05/20 08:47
-	47	@ad<=20010111 and (438/600).ccls. and 'titanium' and 'titanium nitride' and 'tungsten'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/05/20 08:48
-	3	@ad<=20010111 and 'dielectric' with 'titanium' with 'anneal' and 'hydrogen'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/05/20 10:22
-	94	@ad<=20010111 and 'pre metal dielectric layer'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/05/20 09:49
-	37	(@ad<=20010111 and 'pre metal dielectric layer') and 'titanium'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/05/20 09:50
-	10	@ad<=20010111 and 'refractory metal' adj 'hydrogen'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/05/20 10:06
-	0	@ad<=20010111 and 'dielectric' with 'titanium' with 'hydrogen treatment'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/05/20 10:16
-	41	@ad<=20010111 and 'dielectric' with 'titanium' with 'hydrogen'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/05/20 10:16
-	269	@ad<=20010111 and 'titanium' with 'anneal' and 'hydrogen'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/05/20 11:02

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–	38	@ad<=20010111 and 'titanium' with 'anneal' with 'hydrogen'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/26 16:28
–	3	("5494860").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/05/20 11:10
–	443	@ad<=20010111 and (438/627).ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/12/23 09:02
–	600	@ad<=20010111 and (438/628-630).ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/12/23 09:00
–	1110	@ad<=20010111 and (438/637).ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/12/23 09:01
–	57	@ad<=20010111 and (438/475).ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/12/23 09:01
–	2057	@ad<=20010111 and (257/750-753).ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/06/11 11:45
–	311	(@ad<=20010111 and (438/627).ccls.) and 'via' and 'barrier'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/12/23 09:04
–	270	(@ad<=20010111 and (438/628-630).ccls.) and 'via' and 'barrier'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/12/23 09:03
–	423	(@ad<=20010111 and (438/637).ccls.) and 'via' and 'barrier'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/06/11 11:27
–	9	(@ad<=20010111 and (438/475).ccls.) and 'via' and 'barrier'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/12/23 09:03
–	542	(@ad<=20010111 and (257/750-753).ccls.) and 'via' and 'barrier'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/12/23 09:03
–	169	(@ad<=20010111 and (438/637).ccls.) and 'Ti' with 'barrier'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/06/11 11:29
–	1	@ad<=20010111 and 'Ti' with 'barrier' same 'anneal' with 'hydrogen'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/06/11 11:31

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-	4	@ad<=20010111 and 'Ti' same 'barrier' same 'anneal' with 'hydrogen'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/09 13:24
-	1035	@ad<=20010111 and (257/750-753).ccls. and 'barrier'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/06/11 11:47
-	4	@ad<=20010111 and 'TiN' same 'anneal' same 'hydrogen plasma'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/09 13:35
-	377	@ad<=20010111 and 'RTP' same 'titanium'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/09 13:45
-	175	@ad<=20010111 and 'anneal' same 'titanium' same 'plasma'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/09 14:00
-	3	@ad<=20010111 and 'anneal' same 'conductive liner'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/09 14:04
-	35	@ad<=20010111 and 'rapid thermal' same 'conductive' same 'hydrogen'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/09 14:06
-	725	@ad<=20010111 and 'rapid thermal' same 'conductive'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/09 14:06
-	376	@ad<=20010111 and 'rapid thermal' same 'conductive' and 'plasma'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/09 14:07
-	5	@ad<=20010111 and 'rapid thermal' same 'conductive' and 'plasma anneal'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/09 14:11
-	2	@ad<=20010111 and 'rapid thermal' same 'Ti' and 'treating' same 'hydrogen'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/10 08:59
-	2	@ad<=20010111 and 'hydrogen treatment' same 'ti' same 'tin'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/09 14:38
-	123	@ad<=20010111 and 'hydrogen plasma' same 'treatment' same 'metal'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/09 14:56
-	6	@ad<=20010111 and 'H.sub.2 plasma' same 'titanium' same 'TiN'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 09:51

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-	13	@ad<=20010111 and 'H.sub.2 plasma' same 'titanium'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 09:52
-	0	@ad<=20010111 and 'H.sub.2 plasma' same 'refractory metal'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/09 15:18
-	50	@ad<=20010111 and 'H.sub.2 plasma' same 'metal'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/09 15:18
-	16	@ad<=20010111 and 'H.sub.2 plasma' with 'metal'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/09 15:50
-	8	@ad<=20010111 and 'H.sub.2 plasma' with 'tantalum'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/09 15:53
-	3	@ad<=20010111 and 'titanium silicide' same 'H.sub.2 plasma'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/09 15:54
-	7	@ad<=20010111 and 'silicide' same 'H.sub.2 plasma'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/09 15:54
-	710	@ad<=20010111 and 'hydrogen' same 'treatment' same 'conductive'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/10 08:54
-	6	@ad<=20010111 and 'rapid thermal anneal' and 'hydrogen' same 'treatment' same 'conductive'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/10 08:54
-	10	@ad<=20010111 and 'rapid thermal' same 'conductive' and 'treating' same 'hydrogen'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/10 09:06
-	169	@ad<=20010111 and 'conductive' same 'treating' same 'hydrogen'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/10 09:06
-	7	@ad<=20010111 and 'conductive' same 'treating' same 'hydrogen plasma'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/10 09:06
-	0	@ad<=20010111 and 'conductive barrier' same 'anneal' same 'plasma treament'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/26 15:45
-	0	@ad<=20010111 and 'barrier' with 'anneal' same 'hydrogen treament'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/26 15:46

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-	644	@ad<=20010111 and 'barrier' with 'anneal'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/26 15:46
-	290	@ad<=20010111 and 'barrier' with 'anneal' and 'plasma'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/26 15:47
-	0	@ad<=20010111 and 'barrier' with 'anneal' same 'ashing'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/26 15:47
-	54	@ad<=20010111 and 'barrier' with 'anneal' same 'plasma'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/26 16:04
-	3	@ad<=20010111 and 'barrier' with 'anneal' same 'plasma' with 'cleaning'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/26 15:48
-	0	@ad<=20010111 and 'anneal' with 'conductive liner' same 'plasma'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/26 16:05
-	21	@ad<=20010111 and 'anneal' with 'conductive' same 'plasma'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/26 16:05
-	42	@ad<=20010111 and 'titanium' with 'anneal' with 'hydrogen'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 08:13
-	1	@ad<=20010111 and 'anneal' with 'titanium' and 'hydrogen' adj1 'treatment'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 07:29
-	14	@ad<=20010111 and 'H.sub.2 plasma' same 'titanium'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 07:46
-	4	(("5246881") or ("5610106")).PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 07:46
-	31	@ad<=20010111 and 'barrier' with 'anneal' with 'hydrogen'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 07:51
-	7	@ad<=20010111 and 'anneal' with 'titanium' same 'clean' with 'native oxide'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 08:21
-	8	@ad<=20010111 and 'titanium' with 'anneal' same 'hydrogen' same 'plasma'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 08:29

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-	9	@ad<=20010111 and 'silicide' same 'clean' adj1 'oxide'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 08:39
-	7	@ad<=20010111 and 'annealing' with 'adhesive' same 'titanium'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 09:12
-	57	@ad<=20010111 and 'titanium' same 'rapid' with 'thermal' same 'native' adj1 'oxide'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 08:47
-	28	@ad<=20010111 and 'titanium' with 'rapid' with 'thermal' same 'native' adj1 'oxide'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 08:47
-	2	@ad<=20010111 and 'annealing' with 'conductive liner'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 09:13
-	45	@ad<=20010111 and 'anneal' with 'titanium' and 'remove' adj1 'oxide'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 09:14
-	4	@ad<=20010111 and 'annealing' with 'conductive' same 'remove' adj1 'oxide'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 09:22
-	16	@ad<=20010111 and 'annealing' with 'conductive' same 'hydrogen' with 'oxide'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 10:18
-	21	@ad<=20010111 and 'annealing' with 'conductive' and 'hydrogen plasma'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 09:23
-	1	@ad<=20010111 and 'conductive barrier' same 'H.sub.2 plasma'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 09:51
-	14	@ad<=20010111 and 'H.sub.2 plasma' same 'titanium'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 10:04
-	10	@ad<=20010111 and 'H.sub.2 plasma' same 'tantalum'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 10:13
-	41	@ad<=20010111 and 'H.sub.2' with 'plasma' same 'tantalum'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 10:04
-	166	@ad<=20010111 and 'H.sub.2' with 'plasma' same 'titanium'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 10:04

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-	0	@ad<=20010111 and 'tantalum oxide' with 'remove' with 'H.sub.2 plasma'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 10:14
-	0	@ad<=20010111 and 'titanium' adj1 'oxide' with 'remove' with 'H.sub.2 plasma'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 10:14
-	0	@ad<=20010111 and 'titanium' adj1 'oxide' same 'remove' same 'H.sub.2 plasma'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 10:14
-	0	@ad<=20010111 and 'tantalum oxide' with 'clean' with 'H.sub.2 plasma'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 10:14
-	0	@ad<=20010111 and 'titanium' adj1 'oxide' same 'clean' same 'H.sub.2 plasma'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 10:14
-	17	@ad<=20010111 and 'oxide' same 'clean' same 'H.sub.2 plasma'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 10:16
-	0	@ad<=20010111 and 'clean' same 'titanium oxide' same 'ammonia' with 'plasma'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 10:16
-	0	@ad<=20010111 and 'annealing' adj2 'titanium' same 'treat' with 'hydrogen'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 10:19
-	0	@ad<=20010111 and 'annealing' same 'titanium' same 'treat' same 'hydrogen'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 10:19
-	31	@ad<=20010111 and 'annealing' same 'titanium' and 'hydrogen' adj1 'treatment'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 11:41
-	8	@ad<=20010111 and 'annealing' same 'tantalum' and 'hydrogen' adj1 'treatment'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 10:33
-	1	@ad<=20010111 and 'annealing' same 'tantalum' and 'hydrogen' adj1 'treat'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 10:31
-	393	@ad<=20010111 and 'annealing' with 'tantalum'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 10:34
-	20	@ad<=20010111 and 'oxide' same 'remove' same 'H.sub.2 plasma'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 10:33

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-	16	(@ad<=20010111 and 'annealing' with 'tantalum') and 'native oxide'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 10:34
-	65	@ad<=20010111 and 'annealing' same 'titanium' same 'native oxide'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 10:50
-	0	@ad<=20010111 and 'native oxide' adj1 'on' with 'titanium' same 'clean'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 10:51
-	33	@ad<=20010111 and 'native oxide' with 'titanium' same 'clean'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 10:51
-	58	@ad<=20010111 and 'native oxide' with 'titanium' same 'remove'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 11:03
-	6	@ad<=20010111 and 'native oxide' adj1 'titanium' same 'remove'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 11:06
-	35	@ad<=20010111 and 'removing' with 'native oxide' with 'titanium'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 11:06
-	23	@ad<=20010111 and 'annealing' with 'titanium' with 'native oxide'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 11:44
-	21	@ad<=20010111 and 'RTP' with 'titanium' with 'oxide'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 12:20
-	18	@ad<=20010111 and 'RTP' same 'titanium oxide'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 11:50
-	14	@ad<=20010111 and 'RTA' same 'titanium oxide'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 12:15
-	69	@ad<=20010111 and 'RTA' same 'tantalum'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 12:16
-	11	@ad<=20010111 and 'RTA' same 'tantalum' adj1 'oxide'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 12:17
-	11	@ad<=20010111 and 'RTA' same 'tantalum oxide'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 12:17

-	6	@ad<=20010111 and 'RTP' with 'titanium oxide'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 12:30
-	0	@ad<=20010111 and 'RTP' and 'titanium oxide' and 'native oxide' and 'H.sub.2 plasma'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 12:33
-	29	@ad<=20010111 and 'hydrogen treatment' same 'reduce' with 'oxide'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 12:42
-	3	@ad<=20010111 and 'hydrogen plasma' same 'Ti' same 'reduce' with 'oxide'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 12:43
-	160	@ad<=20010111 and 'hydrogen' same 'titanium' same 'reduce' with 'oxide'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 12:45
-	2	@ad<=20010111 and 'anneal' with 'titanium' same 'hydrogen' same 'reduce' with 'oxide'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 12:48
-	0	@ad<=20010111 and 'plasma hydrogen' with 'reduce' with 'oxide'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 12:49
-	13	@ad<=20010111 and 'H.sub.2' with 'plasma' with 'reduce' with 'oxide'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 13:01
-	1	@ad<=20010111 and 'silicide' same 'plasma clean' with 'oxide'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 12:55
-	3	@ad<=20010111 and 'titanium' same 'plasma clean' with 'oxide'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 12:56
-	8	@ad<=20010111 and 'titanium' same 'plasma clean'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 12:56
-	3	@ad<=20010111 and 'NH.sub.3' with 'plasma' with 'remove' with 'oxide'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/30 14:00

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